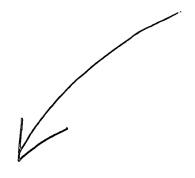
Search Text Type	USPAT	2000/09/ 20 15:46 2000/09/ 20 15:58 2000/09/ 20 15:58 2000/09/ 20 15:59 2000/09/ 20 16:00 2000/09/ 20 16:04 2000/09/ 20 16:05 2000/09/ 20 16:05 2000/09/ 20 16:05 2000/09/ 20 16:36	m r e r r n D 0 0 0 0 0 0 0 0 0 0 0 0 0 0 0 0 0 0
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## BRS L4 \$\frac{4}{37} 3,4-epoxycyclohexylmethyl-3,4-epoxycyclohexene adj carboxylate 5	USPAT USPAT USPAT USPAT USPAT USPAT USPAT USPAT USPAT	2000/09/ 20 15:59 2000/09/ 20 16:00 2000/09/ 20 16:03 2000/09/ 20 16:04 2000/09/ 20 16:05 2000/09/ 20 16:36	0
4 LM 6 5 BRS L6 0 4 and 5 6 BRS L5 27 (Epon adj "1050") or (ECN adj ("1273" "1280" "9495")) 7 BRS L7 0 5 and (25\$acrylate 25\$methacrylate) 8 BRS L8 0 5 and (acrylate methacrylate) 9 BRS L9 29 5 and (acrylate methacrylate) and (cycloaliphatic adj epoxy) 10 BRS L10 4 5 525/482.ccls. 11 BRS L11 88 sr adj "351" 12 BRS L12 24 522/142,144.ccls. 13 BRS L13 24 (522/142 522/144).ccls. 14 BRS L14 24 52 (522/142 522/144).ccls. not 10	USPAT USPAT USPAT USPAT USPAT USPAT USPAT USPAT	2000/09/ 20 16:00 2000/09/ 20 16:03 2000/09/ 20 16:04 2000/09/ 20 16:05 2000/09/ 20 16:36	0
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15 BRS L15 24 (522/142 522/144).ccls. not 525/482.ccls.	USPAT	20 18:24 2000/09/ 20 18:25	0
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Page 1 (CHamilton, 09/20/2000, EAST Version: 1.01.0015)

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2	BRS	L2	16	uvr same	USP.A T	2000/09/ 20 15:58			0
3	BRS	L3	:	364@poxycycl ohexylmethyl-3 ,4-epoxycycloh	-	2000/09/ 20 15:58		**	0
4	BRS	L4	37	6x energy cycli ohexylmethyl-3 ,4-epoxycycloh exene adj	USPA T	2000/09/ 20 15:59		***	0
5	BRS	L6	0	carboxylate 4 and 5	USPA T	2000/09/ 20 16:00		"	0
6	BRS	L5	27 8	(Epon adj "1050") or (ECN adj	USPA T	2000/09/ 20 16:03			0
7	BRS	L7	0	6 1273 "12 (25 \$acrylate	USPA T	2000/09/ 20 16:04	"		0
8	BRS	L8	: :	3510 (skayia) methacrylate)		2000/09/ 20 16:05	7	1	0
9	BRS	L9	29	5 and (acrylate methacrylate) and (cycloaliphatic		2000/09/ 20 16:36	-		0
10	BRS	LIO	18 4	adj epoxy) 525/482.ccls.	USPA T	2000/09/ 20 17:20	-	(O
11	BRS	LII	88	sr adj "351"	_ :	2000/09/ 20 18:23		(O
12	BRS	L12		522/142,144 .ccls.	USPA.		1		
13	BRS	L13	24 5	(522/142 522/144).ccls	USPA	2000/09/ 20 18:24		c)
14	BRS	L14	24 (**************************************	USPA	2000/09/ 20 18:24	-	0)
15	BRS	L15	24	502/042	JSPA	2000/09/ 20 18:25		0)

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	y P e	15	Search Text	DB	s Time Stamp	n n			- F
ı	Įs,	0	cyroacure same uvr same "6105"		2000/09/20 15:46		1	1	
2	B R S	6	Cyracure same uvr same "6105"		2000/09/20	<u> </u>	•	C	
3	R S	U	3,4-epoxycyclohexylmethyl-3,4-epoxycyclohexene carboxylate		2000/09/20 15:58		•	C	י
4	B R S	1 3 7	3,4-epoxycyclohexylmethyl-3,4-epoxycyclohexene adj carboxylate		2000/09/20 15:59		-	О	,
5	B R S		(3,4-epoxycyclohexylmethyl-3,4-epoxycyclohexene adj carboxylate) and ((Epon adj "1050") or (ECN adj ("1273" "1280" "9495")))		2000/09/20 16:00			0	
6	B R S	7	(Epon adj "1050") or (ECN adj ("1273" "1280" "9495"))		2000/09/20 16:03			0	
7	B R S	O.	((Epon adj "1050") or (ECN adj ("1273" "1280" "9495"))) and (25\$acrylate 25\$methacrylate)		2000/09/20 16:04			0	
8	B R S		((Epon adj "1050") or (ECN adj ("1273" "1280" "9495"))) and (acrylate methacrylate)		2000/09/20 16:05			0	
9	B R S	2 (((Epon adj "1050") or (ECN adj ("1273" "1280" "9495"))) and (acrylate methacrylate) and (cycloaliphatic adj epoxy)		2000/09/20 16:36			0	
10	B R S	8	525/482.ccls.		2000/09/20 17:20			0	
11	B R S	8 8	sr adj "351"		2000/09/20 18:23			0	
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13	B 2 R 4 S 5		522/142 522/144).ccls.		2000/09/20 18:24			9	
14	B 2 R 4 S 5	1 (522/142 522/144).ccls. not 525/482.ccls.		2000/09/20 18:24	•	1	0	
	B 2 R 4 S 5		522/142 522/144).ccls. not 525/482.ccls.		2000/09/20 19:48	•		غساهسا	
16	s 2	ļ	f-1000 or bf adj "1000"		2000/09/20 18:44	1		9	
17	S 9	('	430/280.1 or 522/2,170).cck.		2000/09/20 19:49		(7	
18	B 4 R 3 S 5	(4	130/280.1 or 522/2,170).ccls. not (525/482 522/144,142).ccls.		2000/09/21 08:57	-	C	The same	
19	§ 1 ጀ		6120974").PN.		2000/09/21 08:58	•	c		
20	Œ.		5965325").PN.	USP AT I	2000/09/21 08:58	<u> </u>	0	The second	
21 6	; 3	(c	resol novolac) near10 (epoxy or epoxid\$5)	USP :	2000/09/21 11:35		0		
E 22 F	3: 3:	(cı	resol novolac novolak or novalac or novalak) near l 0 (epoxy or epoxid\$5)	USP 2	2000/09/21 11:36		0	The state of the s	

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23	BRS	1	1556	(cycloaliphatic epoxycyclohexene epoxycyclohexy1\$20) and (epoxid\$25 or epoxy\$25)		2000/09/21 1:40		TruncationOverLow.Returnsting	

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	B R C S	cyroacure same uvr same "6105"	:	2000/09/20 15:46	1	Ē
	B R S	cyracure same uvr same "6105"		2000/09/20 15:58	<u> </u>	
	B 3 R 7 S 0	3,4-epoxycyclohexylmethyl-3,4-epoxycyclohexene carboxylate	USP AT	2000/09/20 15:58	•	•
	B 3 R 7 S	3,4-epoxycyclohexylmethyl-3,4-epoxycyclohexene adl carboxylate		2000/09/20 15:59	1	
	B R O S	(3,4-epoxycyclohexylmethyl-3,4-epoxycyclohexene adj carboxylate) and ((Epon adj "1050") or (ECN adj ("1273" "1280" "9495")))		2000/09/20 16:00		
	B 2 R 7 S 8	(Epon adj "1050") or (ECN adj ("1273" "1280" "9495"))		2000/09/20 16:03	!	
	B R O S	((Epon adj "1050") or (ECN adj ("1273" "1280" "9495"))) and (25\$acrylate 25\$methacrylate)	USP	2000/09/20 16:04		
	B 1 R 6 S 0	((Epon adj "1050") or (ECN adj ("1273" "1280" "9495"))) and (acrylate methacrylate)		2000/09/20 16:05		
	B 2 R 9 S	((Epon adj "1050") or (ECN adj ("1273" "1280" "9495"))) and (acrylate methacrylate) and (cycloaliphatic adj epoxy)	:	2000/09/20 16:36	-	
ļ	B 1 R 8 S 4	525/482.ccis.		2000/09/20 17:20		
	8 8 8	sr adj "351"		2000/09/20 18:23		
	3 2 3 4 5 5	522/142,144.ccls.		2000/09/20 18:24		
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	2 4 5	522/142 522/144).ccls. not 525/482.ccls.		2000/09/20 18:24		
1	2 4 5	522/142 522/144).ccls. not 525/482.ccls.		2000/09/20 19:48		
	3 2	of-1000 or bf adj "1000"		2000/09/20 18:44		
2	4 3 (9	430/280.1 or 522/2,170).ccls.		2000/09/20 19: 4 9		
t	4 3 (5	430/280.1 or 522/2,170).ccls. not (525/482 522/144,142).ccls.	USP :	2000/09/22 15:59	-	
į	1 ("6120974").PN.	USP :	2000/09/21 08:58		
Ċ	1 ("5965325").PN.	USP 2	2000/09/21 08:58	-	
	3	cresol novolac) near IO (epoxy or epoxid\$5)	USP 2	2000/09/21 1:35		
Ġ	5 (1	cresol novolac novolak or novalac or novalak) near10 (epoxy or epoxid\$5)		2000/09/21	-	

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23	R	1 5 5 8 9	(cycloallphatic epoxycyclohexene epoxycyclohexyl\$20) and (epoxid\$25 or epoxy\$25)	USP AT	2000/09/21 12:02	e Truncadoro vertios Recultarian
24	B R S	5		usp	2000/09/21 12:07	fr
25	R S		(cycloaliphatic epoxycyclohexene epoxycyclohexyl\$15) and (epoxid\$20 or epoxy\$20)	USP AT	2000/09/21 12:03	TruncationOverLov.Recurrent
26 [B R S	5 (0	cycloaliphatic epoxycyclohexene epoxycyclohexy1\$15) and (epoxid\$10 or epoxy)		2000/09/21 12:04	fr fr
7 !	R :	2 (0 ((cresol novolac novolak or novalac or novalak) near10 (epoxy or epoxid\$5)) and (cycloaliphatic epoxycyclohexene epoxycyclohexyf\$15) and (epoxid\$10 or epoxy)) (cresol novolac novolak or novalac or novalak) near10 (epoxy or epoxid\$5)) and		2000/09/21 12:05	
1		3 a	(Cycloaliphatic epoxycyclohexene epoxycyclohexyl\$15) and (epoxid\$10 or epoxy)) ind (acrylate or methacrylate or free adj radical)	•	2000/09/21 12:06	
A 1	٠: I	5: L	(cresol novolac novolak or novalac or novalak) near10 (epoxy or epoxid\$5)) same (cresol novolac novolak or novalac or novalak) near10 (epoxy or epoxid\$5))		2000/09/21 12:08	

	T y	id	Search Text	DBs	Time Stamp	Corren	ErrorD
30	R	7 3 3	((cresol novolac novolak or novalac or novalak) near10 (epoxy or epoxId\$5)) same ((cycloaliphatic epoxycyclohexene epoxycyclohexyl\$15) and (epoxId\$20 or epoxy\$20)	USP AT	2000/09/21 12:12	1 0 0 0 1 1 7 7 7 8 8 7	e TruncadorOverilow.Recument
3 11 1	ĸ.	1	(((cresol novolac novolak or novalac or novalak) near10 (epoxy or epoxid\$5)) same ((cycloaliphatic epoxycyclohexene epoxycyclohexyl\$15) and (epoxid\$20 or epoxy\$20))) and (acrylate or methacrylate or free ad radical)	USP AT	2000/09/21 12:11	eff runcation Overlow. Returns fin	
n Aln		7 : ((cycloaliphatic epoxycyclohexene epoxycyclohexyl\$10) and (epoxid\$10 or epoxy))		2000/09/21 12:13	og fr	
B 3 R	1	S (((cresol novolac novolak or novalac or novalak) near10 (epoxy or epoxid\$5)) same (cycloaliphatic epoxycyclohexene epoxycyclohexyl\$10) and (epoxid\$10 or epoxyl))	USP :	2000/09/22 16:00		C
- [1	1	1	"4555414").PN.	usp :	2000/09/21 13:54		0

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2	F	} L 2		5	(130/2007) G 322/2/170/.ccs. not (323/462 322/144,142).ccs.	ΑТ	2000/09/2 2 15:59			0
3	F	3 2 3	4	5 1 8	(((cresol novolac novolak or novalac or novalak) near10 (epoxy or epoxid\$5)) same ((cycloaliphatic epoxycyclohexene epoxycyclohexyl\$10) and (epoxid\$10 or epoxy))) and (methacrylate or acrylate or free adj.radical\$3)	USP AT	2000/09/2 2 16:00			O
4	F	3 L	4	2 8	12 did 13		2000/09/2 2 16:01			0

FILE 'USPATFULL' ENTERED AT 16:17:02 ON 20 SEP 2000 L7 129 S L6 L8 0 S L1(P) (NOVOLAC OR CRESOL) AND FREE RADICAL?

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RN
     7-Oxabicyclo[4.1.0]heptane-3-carboxylic acid, 7-oxabicyclo[4.1.0]hept-3-
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Epikote 171

ER 4221 ERL 4211

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CN
CN
    Unox 221
    Unox 4221
CN
    UP 632
CN
    Uvacure 1500
CN
     UVR 6105
CN
     UVR 6110
CN
     9083-95-8, 11120-79-9, 125053-37-4, 121396-47-2, 129773-39-3, 95078-13-0,
DR
     95078-14-1, 50809-37-5, 50861-60-4, 61489-54-1, 65430-69-5, 111483-58-0,
     137607-28-4, 146123-76-4, 30350-17-5, 39354-66-0, 52725-58-3,
189201-55-6,
     216496-08-1, 251369-29-6
     (C14 H20 O4)x
MF
     PMS, COM
CI
PCT Epoxy resin, Polyester
                 BIOSIS, CA, CAPLUS, CHEMLIST, CIN, IFICDB, IFIPAT, IFIUDB,
     STN Files:
LC
       PROMT, TOXLINE, TOXLIT, USPATFULL
                     NDSL**, TSCA**
     Other Sources:
         (**Enter CHEMLIST File for up-to-date regulatory information)
     CM
     CRN 2386-87-0
     CMF C14 H20 O4
            1589 REFERENCES IN FILE CA (1967 TO DATE)
             119 REFERENCES TO NON-SPECIFIC DERIVATIVES IN FILE CA
            1591 REFERENCES IN FILE CAPLUS (1967 TO DATE)
=> s epon and 1050
           535 EPON
           182 1050
L2
             6 EPON AND 1050
=> s epon 1050
           535 EPON
           182 1050
             0 EPON 1050
L3
                 (EPON(W)1050)
=> d 12 6
     ANSWER 6 OF 6 REGISTRY COPYRIGHT 2000 ACS
L2
     25068-38-6 REGISTRY
RN
     Phenol, 4,4'-(1-methylethylidene)bis-, polymer with (chloromethyl)oxirane
CN
```

```
(9CI)
            (CA INDEX NAME)
OTHER NAMES:
    1-Chloro-2, 3-epoxyrropane-4, 4'-isopropylidenediph
                                                           1 polymer
CN
CN
     2,2-Bis(4-hydroxyphenyl)propane-epichlorohydrin copolymer
CN
     2,2-Bis(4-hydroxyphenyl)propane-epichlorohydrin polymer
CN
     2,2-Bis(hydroxyphenyl)propane-epichlorohydrin copolymer
CN
     2,2-Bis(p-hydroxyphenyl)propane-epichlorohydrin condensate
CN
     2,2-Bis(p-hydroxyphenyl)propane-epichlorohydrin copolymer
CN
     2,2-Bis(p-hydroxyphenyl)propane-epichlorohydrin polymer
CN
     2,2-Diphenylolpropane-epichlorohydrin polymer
CN
     4,4'-Dihydroxydiphenylpropane-epichlorohydrin polymer
CN
     4,4'-Isopropylidenediphenol-epichlorohydrin polymer
CN
     684EK40
CN
    A 39
CN
CN
     A 39 (polymer)
CN
    AA 2662
CN
    AD 301
    Adbond 5300A
CN
    Adeka EP 4300
CN
    Adeka EP 5100-75X
CN
    Adeka EP 5700
CN
CN
    Adeka EP 5900
    Adeka Optomer KRM 2410
CN
CN
    AER 331
    AER 337
CN
    AER 661
CN
    AER 661x-75
CN
    AER 664
CN
    AER 664P
CN
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CN
    AER 669
CN
CN
     Aicarpox BL
CN
     Aicarpox BL 100
CN
     Aicarpox BS
     Aicarpox BS 001
CN
     Aicarpox BS 0010G
CN
     Aicarpox BS 001SS
CN
CN
     Aicarpox BS 004
     Aicarpox BS 004S
CN
CN
     AP 2
     Araldite 471X75
CN
     Araldite 527
CN
CN
     Araldite 6004
     Araldite 6005
CN
     Araldite 6010
CN
CN
     Araldite 6020
     Araldite 6071
CN
     Araldite 6084
CN
     Araldite 6097
CN
     Araldite 6099
CN
CN
     Araldite 6100
CN
     Bisphenol A-Epon 829 copolymer
CN
     Epiclon 1050
CN
     Epiclon 1050-70
CN
     Epon 1001
CN
     Epon 1001B80
CN
     Epon 1001F
CN
     Epon 1001X75
CN
     Epon 1001X80
CN
     Epon 1002
CN
     Epon 1002F
CN
     Epon 1004
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CN

CN

Epon 1004F

Epon 1007

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Fbou Inn/F
CN
     Epon 1009
     Epon 1009F
CN
     Epon 1010
CN
     Epon 1104
CN
     Epon 2001
CN
     Epon 2002
CN
     Epon 2004
CN
     Epon 201
CN
     Epon 2042
CN
     Epon 287
CN
     Epon 291
CN
     Epon 384
CN
     Epon 820
     Epon 825
CN
     Epon 826
CN
CN
     Epon 827
CN
     Epon 828
CN
     Epon 828LS
CN
     Epon 828RS
CN
     Epon 829
CN
     Epon 830
CN
     Epon 834
CN
     Epon 834X90
CN
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CN
     Epon 880
CN
     Epon 9102
CN
     Epon 9302
CN
     Epon DPS 2012
CN
     Epon DPS 2014
CN
    Epon DRH 201
CN
    Eponol 53
CN
    Eponol 53B40
CN
    Eponol 53L32
CN
    Eponol 55
CN
    Eponol 55B40
CN
    Eponol 55BQ20
    Eponol 55L32
ADDITIONAL NAMES NOT AVAILABLE IN THIS FORMAT - Use FCN, FIDE, or ALL for
     DISPLAY
     26402-79-9
AR
     8000-31-5, 9049-54-1, 9050-21-9, 9081-91-8, 9083-76-5, 9084-94-0,
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     61356-27-2, 61711-38-4, 61991-18-2, 62169-28-2, 62169-29-3, 108556-05-4,
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37348-5/-5, 3/35/-/3-6, 3/360-33-3, 11131/ 32 0, 13013/ 20 /,
138361-18-9,
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     52627-94-8, 52907-38-7, 53027-88-6, 53127-14-3, 53200-30-9, 101027-12-7,
     107991-47-9, 110158-22-0, 117216-90-7, 118340-04-8, 157321-42-1,
     160674-45-3, 179607-24-0, 183581-68-2, 187619-11-0, 222835-65-6,
     222835-66-7, 222835-68-9, 222835-69-0, 222835-70-3, 222835-72-5,
     222835-74-7, 222835-77-0
     (C15 H16 O2 . C3 H5 Cl O) x
MF
     PMS, COM
CI
PCT Epoxy resin
                  BIOBUSINESS, BIOSIS, CA, CANCERLIT, CAPLUS, CHEMCATS,
LC
     STN Files:
       CHEMLIST, CIN, CSCHEM, CSNB, IFICDB, IFIPAT, IFIUDB, MEDLINE, MSDS-OHS,
      NIOSHTIC, PDLCOM*, PIRA, PLASPEC*, PROMT, RTECS*, TOXLINE, TOXLIT,
      USPATFULL
         (*File contains numerically searchable property data)
     Other Sources: DSL**, TSCA**
         (**Enter CHEMLIST File for up-to-date regulatory information)
     CM
          1
     CRN 106-89-8
     CMF C3 H5 Cl O
     CH2-Cl
     CM
     CRN 80-05-7
     CMF C15 H16 O2
                      OH
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22927 REFERENCES IN FILE CA (1967 TO DATE) 3693 REFERENCES TO NON-SPECIFIC DERIVATIVES IN FILE CA 22950 REFERENCES IN FILE CAPLUS (1967 TO DATE)

=> file ca

COST IN U.S. DOLLARS SINCE FILE TOTAL ENTRY SESSION FULL ESTIMATED COST 25.04 25.19 FILE 'CA' ENTERED AT 1.5:00 ON 20 SEP 2000
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FILE COVERS 1967 - 15 Sep 2000 VOL 133 ISS 13 FILE LAST UPDATED: 15 Sep 2000 (20000915/ED)

This file contains CAS Registry Numbers for easy and accurate substance identification.

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Now you can extend your author, patent assignee, patent information, and title searches back to 1907. The records from 1907-1966 now have this searchable data in CAOLD. You now have electronic access to all of CA: 1907 to 1966 in CAOLD and 1967 to the present in CA on STN.

=> d his

(FILE 'HOME' ENTERED AT 16:13:27 ON 20 SEP 2000)

FILE 'REGISTRY' ENTERED AT 16:13:44 ON 20 SEP 2000

1 S CYRACURE AND 6105

L2 6 S EPON AND 1050

L3 0 S EPON 1050

FILE 'CA' ENTERED AT 16:15:00 ON 20 SEP 2000

=> s 11

L4 1632 L1

=> s 14 and (novolac or cresol)

1288 NOVOLAC

28558 CRESOL

L5 32 L4 AND (NOVOLAC OR CRESOL)

=> s 15 and (free radical? or acrylate? or methacrylate?)

755362 FREE

233059 RADICAL?

55958 FREE RADICAL?

(FREE (W) RADICAL?)

127658 ACRYLATE?

143880 METHACRYLATE?

L6 4 L5 AND (FREE RADICAL? OR ACRYLATE?) OR METHACRYLATE?)

=> d all 1-4

L6 ANSWER 1 OF 4 CA COPYRIGHT 2000 ACS

AN 125:88164 CA

TI Hydrolytic stable glass fiber-reinforced polyester resins

```
PA General Electric Company, USA SO Eur. Pat. Appl. 0 pp.
    CODEN: EPXXDW
DT Patent
LA English
    ICM C08L067-02
IC
     ICS C08L063-00
     37-6 (Plastics Manufacture and Processing)
     Section cross-reference(s): 38
FAN.CNT 1
                                         APPLICATION NO. DATE
                    KIND DATE
     PATENT NO.
     _____
    EP 712899 A1 19960522
EP 712899 B1 19990602
                                          EP 1994-118257 19941119
        R: DE, ES, FR, GB, IT, NL
     ES 2131620 T3 19990801
US 5731390 A 19980324
                                          ES 1994-118257 19941119
                                          US 1995-434132 19950502
PRAI EP 1994-118257 19941119
    A thermoplastic resin compn. having improved hydrolytic stability having
     in admixt. a satd. polyester resin such as poly(butylene terephthalate),
     an epoxy novolac, a glass fiber reinforcing filler and a
     catalyst such as sodium stearate. Preferably the polyester component is
     selected from the group consisting of poly(butylene terephthalate),
     poly(ethylene terephthalate), poly(1,4-cyclohexanedimethanol
     terephthalate) and blends of any of the foregoing, and is present in an
     amt. ranging from .apprx.15-80% based on the wt. of the total compn. The
     preferred epoxy compd. is an ortho cresol novolac
     epoxy resin.
ST
     hydrolytic stable polyester epoxy glass composite; impact resistant
     polyester glass extrusion compn; molding compn novolac epoxy
     polyester glass
ΙT
    Fireproofing agents
     Impact-resistant materials
        (prodn. of hydrolytic stable glass fiber-reinforced polyester resins)
ΙT
     Glass fibers, uses
     RL: MOA (Modifier or additive use); USES (Uses)
        (prodn. of hydrolytic stable glass fiber-reinforced polyester resins)
ΙT
     Polyesters, uses
     RL: POF (Polymer in formulation); TEM (Technical or engineered material
     use); USES (Uses)
        (prodn. of hydrolytic stable glass fiber-reinforced polyester resins)
ΙT
     Phenolic resins, uses
     RL: MOA (Modifier or additive use); USES (Uses)
        (epoxy, novolak, ECN-type; prodn. of hydrolytic stable glass
        fiber-reinforced polyester resins)
ΙT
    Rubber, synthetic
     RL: MOA (Modifier or additive use); USES (Uses)
        (ethylene-glycidyl methacrylate-Me acrylate, impact
        modifier; prodn. of hydrolytic stable glass fiber-reinforced polyester
        resins)
     Plastics, reinforced
IT
     RL: POF (Polymer in formulation); TEM (Technical or engineered material
     use); USES (Uses)
        (glass fiber-, prodn. of hydrolytic stable glass fiber-reinforced
        polyester resins)
ΤТ
     Rubber, butadiene-styrene, uses
     RL: MOA (Modifier or additive use); USES (Uses)
        (hydrogenated, block, triblock, impact modifier; prodn. of hydrolytic
        stable glass fiber-reinforced polyester resins)
ΙT
     Epoxy resins, uses
     RL: MOA (Modifier or additive use); USES (Uses)
        (phenolic, novolak, ECN-type; prodn. of hydrolytic stable glass
        fiber-reinforced polyester resins)
     822-16-2, Sodium stearate
ΤТ
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van nermond, Jan

```
RL: CAT (Catalyst use); USES (USES)
    (prodn. of hypolytic stable glass fiber-reinferced polyester resins) 25085-98-7, ERL 21
    RL: MOA (Modifier or additive use); USES (Uses)
        (prodn. of hydrolytic stable glass fiber-reinforced polyester resins)
     24936-69-4, Poly(1,4-cyclohexanedimethanol terephthalate) 24968-12-5,
ΙT
     Poly(butylene terephthalate) 25037-99-4, 1,4-Cyclohexanedimethanol-
     terephthalic acid copolymer 25038-59-9, Poly(ethylene terephthalate),
            26062-94-2, Poly(butylene terephthalate)
     RL: POF (Polymer in formulation); TEM (Technical or engineered material
     use); USES (Uses)
        (prodn. of hydrolytic stable glass fiber-reinforced polyester resins)
     106107-54-4
IΤ
     RL: MOA (Modifier or additive use); USES (Uses)
        (rubber, hydrogenated, block, triblock, impact modifier; prodn. of
        hydrolytic stable glass fiber-reinforced polyester resins)
     51541-08-3, Ethylene-glycidyl methacrylate-methyl
ΙT
     acrylate copolymer
     RL: MOA (Modifier or additive use); USES (Uses)
        (rubber, impact modifier; prodn. of hydrolytic stable glass
        fiber-reinforced polyester resins)
    ANSWER 2 OF 4 CA COPYRIGHT 2000 ACS
L6
    107:178176 CA
AN
    Use of aromatic amines for setting epoxide resins
TI
IN
    Nichols, Gus
PΑ
    USA
SO
    U.S., 9 pp.
    CODEN: USXXAM
DT
    Patent
LA
    English
    ICM C08G059-54
ICS C08G059-68
NCL 528088000
     42-9 (Coatings, Inks, and Related Products)
    Section cross-reference(s): 25, 27, 37
FAN.CNT 1
    PATENT NO.
                    KIND DATE
                                          APPLICATION NO. DATE
                     A 19870526 US 1984-593592 19840326
     ____________
PΙ
    US 4668757
    Arom. amines and their alkyl, imine, amide, and/or imide group-contg.
    derivs. are used with epoxy resins and catalysts comprising phenols,
    cresols, etc., in the prepn. of compns. which cure at ambient temps.
     compns. are useful as 2-component coating or casting systems. Condensing
    2.0 mol 2,4-bis(p-aminobenzyl)aniline with 3.0 mol phthalic anhydride to
    remove 3.0 mol H2O gave an imide-amine, which (47 g) was mixed with 28 q
     iso-BuCOMe and 25 g toluene to give a soln. The soln. was mixed an equal
     amt. of a soln. comprising Epon 828 51.3, o-cresol 5, toluene
    12, and iso-BuCOMe 31.7 g to give a coating compn. which had pot life 1.5
    h and gave coatings which were tackfree after 3 h and hard after 12 h.
    Without o-cresol, the films remained tacky for weeks.
     amine arom hardening epoxy coating; phenol catalyst hardening epoxy
amine;
    cresol catalyst hardening epoxy amine; amide amine arom hardening
    epoxy; imide amine arom hardening epoxy; crosslinking epoxy arom amine
     catalyst; imine amine arom hardening epoxy
ΙT
    Crosslinking agents
       (arom. amines, for epoxy resins in presence of phenol catalysts)
TT
     Phenols, uses and miscellaneous
    RL: CAT (Catalyst use); USES (Uses)
        (catalysts, for curing of epoxy resins by arom. amines)
    Epoxy resins, uses and miscellaneous
ΤТ
    RL: USES (Uses)
```

(curing of, by arom. amines, catalysts for)

ΙT

Coating materials

```
(epoxy resin-arom. amine compus., cuting of, catalyses for
      Crosslinking cathysts
, IT
         (phenols, for poxy resins by arom. amines)
      Amides, uses and miscellaneous
 TΤ
      Amines, uses and miscellaneous
      RL: USES (Uses)
         (aryl, curing by, of epoxy resins, catalysts for)
 ΙT
      Crosslinking
         (room-temp., of epoxy resins by arom. amines in presence of phenols)
      95-48-7, o-Cresol, uses and miscellaneous 95-57-8,
 ΙT
                      1300-71-6, Xylenol 25154-52-3, Nonylphenol
      o-Chlorophenol
      28805-86-9, Butylphenol
      RL: CAT (Catalyst use); USES (Uses)
         (catalysts, for curing of epoxy resins with arom. amines)
      62-53-3D, Aniline, reaction products with acrylic compds.
                                                                 64-18-6D,
      Formic acid, reaction products with arom. amines 79-06-1D, reaction
      products with arom. amines 79-14-1D, Hydroxyacetic acid, reaction
      products with arom. amines 80-08-0D, Bis(4-aminophenyl)sulfone,
 reaction
      products with arom. dicarboxylic anhydrides
                                                  85-42-7D, Hexahydrophthalic
      anhydride, reaction products with arom. amines 85-43-8D,
      Tetrahydrophthalic anhydride, reaction products with arom. amines
      85-44-9D, reaction products with arom. amines 101-77-9D, reaction
      products with carboxylic anhydrides 101-80-4D, Bis(4-aminophenyl)
 ether.
      reaction products with dicarboxylic anhydrides and acrylic compds.
      107-13-1D, reaction products with arom. amines 108-31-6D, Maleic
      anhydride, reaction products with arom. amines 108-45-2D,
      m-Phenylenediamine, reaction products with acrylic compds.
                                                                   110-26-9D,
      Methylenebisacrylamide, reaction products with arom. amines
      Lauric acid, reaction products with arom. amines 149-57-5D,
      2-Ethylhexanoic acid, reaction products with arom. amines
                                                                 818-61-1D,
      reaction products with arom. amines 15625-89-5D, reaction products with
                     17831-71-9D, reaction products with arom. diamines
      arom. amines
      25377-73-5D, Dodecenylsuccinic anhydride, reaction products with arom.
               25584-83-2D, Hydroxypropyl acrylate, reaction products
                            25834-80-4D, 2,4-Bis(4-aminobenzyl)aniline,
      with arom. diamines
 reaction
      products with carboxylic acids and anhydrides and acrylic compds.
      110712-35-1D, reaction products with tetraethylene glycol diacrylate and
      hydroxypropyl acrylate
      RL: USES (Uses)
         (curing by, of epoxy resins in presence of phenol catalysts)
 ΙΤ
      25085-98-7
      RL: USES (Uses)
         (curing of, by arom. amines)
 IT
      25068-38-6
                 37348-52-0
      RL: USES (Uses)
         (curing of, by arom. amines, catalysts for)
 ΙT
                   110712-36-2
      110712-34-0
                                  110742-26-2
      RL: USES (Uses)
         (curing of, catalysts for)
      43078-52-0P 110712-35-1P
 TΤ
                                  110742-25-1P
      RL: PREP (Preparation)
         (manuf. of, for curing of epoxy resins in presence of phenol
 catalysts)
      101-80-4
 ΙT
      RL: RCT (Reactant)
         (reaction of, with Me acrylate)
 ΙT
      552-30-7
      RL: RCT (Reactant)
         (reaction of, with methylenedianiline)
 ΤТ
      96-33-3, Methyl acrylate
      RL: RCT (Reactant)
```

(reaction of, with oxydianiline)

```
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L6
    ANSWER 3 OF 4
   107:124699 CA
AN
TI Process for producing a liquid jet recording head
ΙN
   Noguchi, Hiromichi
    Canon K. K. , Japan
PA
    U.S., 11 pp.
SO
    CODEN: USXXAM
DT
    Patent
LA
    English
ΙC
    ICM B44C001-22
     ICS B29C017-08; C03C015-00; C03C025-06
     74-12 (Radiation Chemistry, Photochemistry, and Photographic and Other
     Reprographic Processes)
FAN.CNT 1
     PATENT NO.
                  KIND DATE
                                         APPLICATION NO. DATE
     -----
    US 4657631 A 19870414 US 1985-811460 19851220 US 4775445 A 19881004 US 1987-1174 19870107
PRAI JP 1984-274689 19841228
    US 1985-811460 19851220
     A liq. jet recording head comprised of a liq. flow path, a liq. ejection
     port, and a liq. ejection energy-generating member arranged along the
liq.
     flow path is comprised of forming a solid layer comprised of pos.
     photoresist on a substrate in accordance with the pattern of the lig.
flow
     path, filling up the recess on the substrate where the solid layer is not
     present with a liq. flow path wall-forming material, and removing the
     solid layer from the substrate. The recording head thus produced is
     inexpensive, precise, highly reliable, and excellent in mech. strength
and
     chem. resistance. A pos. photoresist layer (OZATEC R225) was formed on a
     glass substrate provided with electrothermal transducers as liq. ejecting
     energy-generating members, exposed through a photomask to UV, developed
     with an aq. caustic soda soln., sputtered with a Cr wall layer,
     electrolytically plated with a Ni wall layer, and treated with an
     EtOH-dodecylbenzenesulfonic acid mixt. to remove the resist layer to give
     a liq. jet recording head.
ST
    ink jet recording head prepn; photosensitive resin ink jet head; pos
     photoresist ink jet head
ΙT
    Printing apparatus
        (ink-jet, heads, photofabrication of, using pos. photoresists)
     57835-99-1
TΤ
    RL: USES (Uses)
        (curable resin compns. contg. epoxy resins and, for photofabrication
of
       ink-jet recording heads using pos. photoresist)
ΙT
     37189-54-1 39701-29-6
                             80940-81-4, Acrysirup SY-105 95078-13-0
     95078-16-3
                 110158-77-5
     RL: USES (Uses)
        (curable resin compns. contg., for photofabrication of ink-jet
        recording heads using pos. photoresist)
ΙT
    110158-67-3
    RL: USES (Uses)
        (in photofabrication of ink-jet recording heads)
IT
     7440-02-0, Nickel, uses and miscellaneous
     RL: USES (Uses)
        (ink-jet recording heads with walls of chromium and, photofabrication
       of, using pos. photoresist)
ΙΤ
     7440-47-3, Chromium, uses and miscellaneous
     RL: USES (Uses)
        (ink-jet recording heads with walls of nickel and, photofabrication
of,
```

```
using pos. photoresist,
    9003-09-2, Poly( hyl vinyl ether) 9003-32-1, Poly(ethyl
    acrylate)
    RL: USES (Uses)
        (pos. photoresist contg. trihydroxybenzophenone
       naphthoquinonediazidosulfonate and, in photofabrication of ink-jet
       recording heads)
    107853-40-7
ΙT
    RL: USES (Uses)
        (pos. photoresist from cresol-formaldehyde copolymer and, in
       photofabrication of ink-jet recording heads)
IT
    RL: USES (Uses)
       (pos. photoresist from trihydroxybenzophenone
       naphthoquinonediazidosulfonate and, in photofabrication of ink-jet
       recording heads)
    ANSWER 4 OF 4 CA COPYRIGHT 2000 ACS
    106:103465 CA
    Photocurable epoxy resin potting compositions
TI
    Yamase, Yukio; Takahashi, Eiji
IN
PΑ
    Nippon Soda Co., Ltd., Japan
SO
    Jpn. Kokai Tokkyo Koho, 15 pp.
    CODEN: JKXXAF
DT
    Patent
    Japanese
T.A
    ICM C08G059-34
    ICS C08G059-18; C08G059-68; C08L063-08
ICA G09F009-35
    38-3 (Plastics Fabrication and Uses)
    Section cross-reference(s): 76
FAN.CNT 1
    PATENT NO. KIND DATE
                                        APPLICATION NO. DATE
                                         ______
    JP 61231022 A2 19861015 JP 1985-71700 19850404
PΙ
    Compns. comprise butadiene polymers contg. av. 1.5 epoxy groups/mol.
AB
    10-70, .gtoreq.1 epoxy resin selected from alicyclic, bisphenol A-based,
    bisphenol F-based, novolac, and hydrogenated bisphenol A epoxy
    resins 30-90, a light-sensitive arom. onium salt 0.1-5.0, a (meth)acrylic
    ester 5-50, and a polymerizable substituent-contg. sensitizer 0.001-0.5
    parts. The compns. have good adhesion, temp. shock resistance, and liq.
    crystal compatibility and are esp. useful as potting compns. for liq.
    crystal cells. Thus, a mixt. of epoxidized 1,2-polybutadiene (BF-1000)
    50, an alicyclic epoxy resin (ERL-4299) 50, triphenylsulfonium
    hexafluoroantimonate (50% propylene carbonate soln.) 1,
trimethylolpropane
    triacrylate 20, and vinylanthracene 0.05 part was blended to give a
compn.
    having pot-life >60 days, hardening time 2.0 s, pencil hardness 4 H,
glass
    transition temp. 80.0.degree., and good crosslinking properties.
ST
    liq crystal epoxy resin potting; photocurable epoxy resin potting compn;
    polybutadiene epoxidized potting compn; methylolpropane acrylate
    epoxy resin potting
ΙT
    Light-sensitive materials
       (arom. onium salts, epoxidized polybutadiene-epoxy resin blends contg.
       potting compns. for liq. crystal cells)
IΤ
    Potting compositions
       (epoxidized polybutadiene-epoxy resin blends contg. light-sensitive
       arom. onium salts and sensitizers and (meth)acrylic esters, for liq.
       crystal cells)
ΙT
    Onium compounds
```

(photocurable epoxy potting compns. contg., for liq. crystal cells)

RL: USES (Uses)

Epoxy resins, uses and miscellaneous

ΙT

```
RL: USES (Uses)
     (potting composition). contg., for liq. crystals) Semiconductor deces
ΙT
        (potting compns. for, epoxidized polybutadiene-epoxy resin blends as)
     Rubber, nitrile, compounds
ΙT
     RL: USES (Uses)
        (carboxy-terminated, polymers with epoxy resins, as photocurable
        potting compns. for liq. crystals)
     Rubber, butadiene, compounds
ΙT
     RL: USES (Uses)
        (of 1,2-configuration, epoxidized, potting compns. contg., for liq.
        crystals)
     Crosslinking catalysts
ΙT
        (photochem., vinylanthracene, epoxidized polybutadiene-epoxy resin
        blends contg., potting compns. for liq. crystal cells)
     106-91-2, Glycidyl methacrylate 15625-89-5
                                                     29570-58-9
ΙT
     RL: USES (Uses)
        (photocurable epoxy potting compns. contg., for liq. crystal cells)
     25085-98-7, Celloxide 2021 25085-99-8 29797-71-5, ERL-4299
ΙT
     67185-56-2, Epikote
     RL: USES (Uses)
        (potting compns. contg., for liq. crystal cells)
     9003-17-2D, epoxidized 88506-60-9
IΤ
     RL: USES (Uses)
        (potting compns. contg., for liq. crystals)
ΙT
     9003-18-3
     RL: USES (Uses)
        (rubber, carboxy-terminated, polymers with epoxy resins, as
        photocurable potting compns. for liq. crystals)
ΙT
     9003-17-2
     RL: USES (Uses)
        (rubber, of 1,2-configuration, epoxidized, potting compns. contg., for
        liq. crystals)
     313-39-3, Diphenyliodonium tetrafluoroborate
                                                    1108-21-0,
ΙT
     Triphenylphenacylphosphonium tetrafluoroborate
     RL: USES (Uses)
        (sensitizer, for photocurable epoxy potting compns. for liq. crystal
        cells)
     30521-30-3, Vinylanthracene 106329-98-0
                                                  107109-21-7
ΙT
     RL: USES (Uses)
        (sensitizers, epoxidized polybutadiene-epoxy resin blends contg.,
        potting compns. for liq. crystal cells)
=> d his
     (FILE 'HOME' ENTERED AT 16:13:27 ON 20 SEP 2000)
     FILE 'REGISTRY' ENTERED AT 16:13:44 ON 20 SEP 2000
              1 S CYRACURE AND 6105
L1
L2
              6 S EPON AND 1050
L3
              0 S EPON 1050
     FILE 'CA' ENTERED AT 16:15:00 ON 20 SEP 2000
L4
           1632 S L1
             32 S L4 AND (NOVOLAC OR CRESOL)
L5
              4 S L5 AND (FREE RADICAL? OR ACRYLATE?) OR METHACRYLATE?)
L6
=> file uspatful
COST IN U.S. DOLLARS
                                                  SINCE FILE
                                                                   TOTAL
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FULL ESTIMATED COST

ENTRY

18.18

SESSION

43.37

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DISCOUNT AMOUNTS (FOR QUALIFYING ACCOUNTS)
                                                   DINCE LITE
                                                         NTRY
                                                                 SESSION
                                                         2.12
                                                                   -2.12
' CA SUBSCRIBER PRICE
  FILE 'USPATFULL' ENTERED AT 16:17:02 ON 20 SEP 2000
 CA INDEXING COPYRIGHT (C) 2000 AMERICAN CHEMICAL SOCIETY (ACS)
  FILE COVERS 1971 TO PATENT PUBLICATION DATE: 19 Sep 2000 (20000919/PD)
  FILE LAST UPDATED: 19 Sep 2000 (20000919/ED)
 HIGHEST PATENT NUMBER: US6122767
  CA INDEXING IS CURRENT THROUGH 19 Sep 2000 (20000919/UPCA)
  ISSUE CLASS FIELDS (/INCL) CURRENT THROUGH: 19 Sep 2000 (20000919/PD)
 REVISED CLASS FIELDS (/NCL) LAST RELOADED: Jul 2000
 USPTO MANUAL OF CLASSIFICATIONS THESAURUS ISSUE DATE: Jul 2000
  >>> Page images are available for patents from 1/1/1997. Current
  >>> week patent text is typically loaded by Thursday morning and
  >>> page images are available for display by the end of the day.
                                                                       <<<
  >>> Image data for the /FA field are available the following week.
  >>> Complete CA file indexing for chemical patents (or equivalents) <<<
  >>> is included in file records. A thesaurus is available for the
  >>> USPTO Manual of Classifications in the /NCL, /INCL, and /RPCL
                                                                       <<<
                                                                       <<<
  >>> fields. This thesaurus includes catchword terms from the
  >>> USPTO/MOC subject headings and subheadings. Thesauri are also <<<
  >>> available for the WIPO International Patent Classification
                                                                       <<<
 >>> (IPC) Manuals, editions 1-6, in the /IC1, /IC2, /IC3, /IC4,
                                                                      <<<
 >>> /IC5, and /IC (/IC6) fields, respectively. The thesauri in
                                                                      <<<
 >>> the /IC5 and /IC fields include the corresponding catchword
                                                                      <<<
 >>> terms from the IPC subject headings and subheadings.
                                                                      <<<
 This file contains CAS Registry Numbers for easy and accurate
  substance identification.
  => s 16
             482 L1
            5454 NOVOLAC
           23940 CRESOL
          948540 FREE
          160754 RADICAL?
           36655 FREE RADICAL?
                   (FREE (W) RADICAL?)
           83738 ACRYLATE?
           77339 METHACRYLATE?
  L7
             129 L5 AND (FREE RADICAL? OR ACRYLATE? OR METHACRYLATE?)
 => s l1(p) (novolac or cresol) and free radical?
             482 L1
            5454 NOVOLAC
           23940 CRESOL
               0 L1(P) (NOVOLAC OR CRESOL)
          948540 FREE
          160754 RADICAL?
           36655 FREE RADICAL?
                   (FREE (W) RADICAL?)
               0 L1(P) (NOVOLAC OR CRESOL) AND FREE RADICAL?
 L8
 => d his
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(FILE 'HOME' ENTERED AT 16:13:27 ON 20 SEP 2000)

FILE 'REGISTRY' ENTERED AT 16:13:44 ON 20 SEP 2000

TOTAL

LI 1 S CYRACURE AND 6103
L2 6 S EP AND 1050
L3 0 S EF 1050
_
FILE 'CA' ENTERED AT 16:15:00 ON 20 SEP 2000
L4 1632 S L1
L5 32 S L4 AND (NOVOLAC OR CRESOL)
L6 4 S L5 AND (FREE RADICAL? OR ACRYLATE? OR METHACRYLATE?)
FILE 'USPATFULL' ENTERED AT 16:17:02 ON 20 SEP 2000
L7 129 S L6
L8 0 S L1(P) (NOVOLAC OR CRESOL) AND FREE RADICAL?
=> log y
COST IN U.S. DOLLARS SINCE FILE TOTAL
ENTRY SESSION
FULL ESTIMATED COST 2.14 45.51
DISCOUNT AMOUNTS (FOR QUALIFYING ACCOUNTS) SINCE FILE TOTAL
ENTRY SESSION
CA SUBSCRIBER PRICE 0.00 -2.12

STN INTERNATIONAL LOGOFF AT 16:18:03 ON 20 SEP 2000

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L2		1 S ERL 4221/CN
L3		0 S DEN 428
L4		241 S DEN 438
L5		1 S DEN 438/CN
	FILE	'USPATFULL' ENTERED AT 13:39:50 ON 21 SEP 2000
L6	FILE	'USPATFULL' ENTERED AT 13:39:50 ON 21 SEP 2000 440 S DEN 438
L6 L7	FILE	
	FILE	440 S DEN 438
L7	FILE	440 S DEN 438 320 S L6 AND VISCOSITY
L7 L8	FILE	440 S DEN 438 320 S L6 AND VISCOSITY 18 S L7 AND POISE